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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.	
10/015,640	12/10/2001	Theodore J. Letavic	US010631	7554	
7:	590 07/15/2002				
STEVEN R. F	BIREN	EXAMINER			
•	nics North America Con	NGO, NGAN V			
580 White Plain Tarrytown, NY		ART UNIT	PAPER NUMBER		
, ,			2814		
			DATE MAILED: 07/15/2002		

Please find below and/or attached an Office communication concerning this application or proceeding.

	0.502		- 1-5		AC		
		Application No.		Applicant(s)			
a	•	10/015,640	1	ETAVIC ET AL.			
	Office Action Summary	Examiner	- ,	Art Unit			
1		Ngan Ngo		2814			
	The MAILING DATE of this communication a	appears on the cov r s	h et with th coi	respondence ad	dress		
Period fo		OLV IS SET TO EVOIS	DE 4 MAONITH/S	EDONA			
THE I - External after - If the - If NO - Failu - Any r	ORTENED STATUTORY PERIOD FOR REF MAILING DATE OF THIS COMMUNICATION asions of time may be available under the provisions of 37 CFR SIX (6) MONTHS from the mailing date of this communication. period for reply specified above is less than thirty (30) days, a period for reply is specified above, the maximum statutory perior to reply within the set or extended period for reply will, by state ply received by the Office later than three months after the main displacement. See 37 CFR 1.704(b).	N. 1.136(a). In no event, however reply within the statutory minims od will apply and will expire SIX tute, cause the application to be	r, may a reply be timel um of thirty (30) days v (6) MONTHS from the scome ABANDONED	y filed vill be considered timel e mailing date of this c (35 U.S.C. § 133).	y. ommunication.		
1)	Responsive to communication(s) filed on _	·					
2a) <u></u> ☐	This action is FINAL. 2b)	This action is non-fina	ıl.				
3) Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under <i>Ex parte Quayle</i> , 1935 C.D. 11, 453 O.G. 213. Disposition of Claims							
4) 🖂	Claim(s) 1-20 is/are pending in the applicat	ion.					
	4a) Of the above claim(s) is/are withd	Irawn from considerati	on.				
5)	Claim(s) is/are allowed.						
6)	Claim(s) is/are rejected.						
7)	Claim(s) is/are objected to.						
8)🖂	Claim(s) 1-20 are subject to restriction and/	or election requiremen	nt.				
Applicati	on Papers						
9) 🗌 .	The specification is objected to by the Exam	iner.					
10) ☐ The drawing(s) filed on is/are: a) ☐ accepted or b) ☐ objected to by the Examiner.							
Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).							
11) ☐ The proposed drawing correction filed on is: a) ☐ approved b) ☐ disapproved by the Examiner.							
If approved, corrected drawings are required in reply to this Office action.							
,	The oath or declaration is objected to by the	Examiner.					
_	ınder 35 U.S.C. §§ 119 and 120	•	-				
•	Acknowledgment is made of a claim for fore	eign priority under 35 L	J.S.C. § 119(a)-	(d) or (f).			
a)[☐ All b)☐ Some * c)☐ None of:						
	1. Certified copies of the priority docume	ents have been receive	ed.				
	2. Certified copies of the priority docume	ents have been receive	ed in Application	No			
3. Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)). * See the attached detailed Office action for a list of the certified copies not received.							
14) 🗌 A	acknowledgment is made of a claim for dome	estic priority under 35 l	U.S.C. § 119(e)	(to a provisiona	l application).		
) The translation of the foreign language Acknowledgment is made of a claim for dome	• • •					
Attachmen	t(s)						
2) Notic	e of References Cited (PTO-892) e of Draftsperson's Patent Drawing Review (PTO-948) mation Disclosure Statement(s) (PTO-1449) Paper No(s	5) 🔲 N		PTO-413) Paper No tent Application (PT			

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Restriction to one of the following inventions is required under 35 U.S.C. § 121:

I. Claims 1-13, drawn to a semiconductor device, classified in Class 257, subclass 148.

II. Claims 14-20, drawn to a process for making a semiconductor device, classified in Class 438, subclass 1+.

The inventions are distinct, each from the other because of the following reasons:

Inventions II and I are related as process of making and product made. The inventions are distinct if either or both of the following can be shown: (1) that the process as claimed can be used to make other and materially different product or (2) that the product as claimed can be made by another and materially different process (M.P.E.P. § 806.05(f)). In the instant case unpatentability of the group I invention would not necessarily imply unpatentability of the group II invention, since the device of the group I invention could be made by processes materially different than those of the group II invention. For example, the device in claim 1 can be made without the step of "forming a top oxide layer over the silicon layer" in claim 14.

Because these inventions are distinct for the reasons given above and, as shown by the above different classifications, the fields of search are not co-extensive and separate examination would be required, restriction for examination purposes as indicated is proper.

Applicant is advised that the response to this requirement to be complete must include an election of the invention to be examined even though the requirement be traversed.

Any inquiry concerning this communication should be directed to Examiner Ngan Ngo at telephone number (703) 308-4938. The fax number for the Art unit is (703) 308-7722.

ू^त्Art Unit: 2814

Any inquiry of a general nature or relating to the status of this application or proceeding should be directed to the Group receptionist whose telephone number is (703) 308-0956.

Ngan Van Ngo Primary Examiner

Ngan Ngo

July 8, 2002